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ASME C.9CP1DV1C1

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Sherman  
App. No. : 10/683,727  
Filed : October 10, 2003  
For : SEQUENTIAL CHEMICAL  
VAPOR DEPOSITION  
Examiner : Unknown

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on

May 6, 2005

(Date)

Andrew N. Merickel, Reg. No. 53,317

STATUS LETTER

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Our file for the subject application reveals that there has been no action in this application since it was filed, i.e., October 10, 2003.

Please inform us as to the status of this application.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: May 6, 2005

By: Andrew N. Merickel

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